

2822
PATENT
5310-03000

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application No.: 09/744,877

Filing Date: January 29, 2001

Inventor(s):

Halimaoui et al.

Title: PROCESS FOR FORMING
AN OXIDE LAYER OF NON-
UNIFORM THICKNESS ON
THE SURFACE OF A
SILICON SUBSTRATE

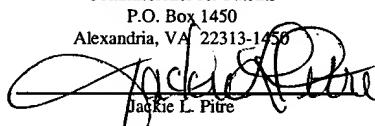
§ Examiner: Novacek, Christy L.
§ Group/Art Unit: 2822
§ Atty. Dkt. No: 5310-03000

CERTIFICATE OF MAILING
UNDER 37 C.F.R. §1.8

DATE OF DEPOSIT: 5-11-03

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Jackie L. Pire

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AMENDMENT; RESPONSE TO OFFICE ACTION MAILED FEBRUARY 27, 2003

Mail Stop Non-Fee Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

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Amendment

Sir:

Please amend the above-captioned application as follows: